



(University of Choice)

**MASINDE MULIRO UNIVERSITY OF
SCIENCE AND TECHNOLOGY
(MMUST)**

**UNIVERSITY EXAMINATIONS
2021/2022 ACADEMIC YEAR
FIRST YEAR FIRST SEMESTER
SPECIAL/SUPPLEMENTARY EXAMINATIONS
FOR THE DEGREE
OF
MASTER OF SCIENCE IN PHYSICS**

COURSE CODE: SPH 850E

COURSE TITLE: THEORY OF SEMICONDUCTORS

DATE: WEDNESDAY 3RD AUGUST, 2022 **TIME:** 8 AM - 11 AM

INSTRUCTIONS TO CANDIDATES

TIME: 3 Hours

Answer any five questions. All questions carry equal marks (14mks)

Symbols used bear the usual meaning.

MMUST observes ZERO tolerance to examination cheating

This Paper Consists of 4 Printed Pages. Please Turn Over. ►

Useful Constants

Electronic charge, $q = 1.6 \times 10^{-19} \text{ C}$

Permittivity of free space, $\epsilon_0 = 8.854 \times 10^{-14} \text{ F/cm}$

Boltzmann constant, $k = 8.62 \times 10^{-5} \text{ eV/K}$

Planck constant, $h = 4.14 \times 10^{-15} \text{ eV} \cdot \text{s}$

Free electron mass, $m_0 = 9.1 \times 10^{-31} \text{ kg}$

Thermal voltage $kT/q = 26 \text{ mV}$ at room temperature

$kT = 0.026 \text{ eV} = 26 \text{ meV}$ at room temperature

$kT \ln(10) = 60 \text{ meV}$ at room temperature

Question One (14mks)

- (a) Distinguish briefly between the following (i) classical free electron theory (ii) Quantum free electron theory and (iii) Band theory of Solids. (6mks)
- (b) Indicate an energy level diagrams the conduction and valence bands, donor and acceptor levels for intrinsic semiconductor. (4mks)
- (c) Explain the concept of drift and diffusion currents and hence derive the relation between diffusion and mobility. (4mks)

Question Two (14mks)

- (a) Define Fermi-Dirac distribution function, $f_F(E)$, electron distribution, $n(E)$ and hole distribution, $p(E)$. Write down the expression of each. (4mks)
- (b) Explain with aid of a diagram the effect of temperature on Fermi-Dirac distribution. (5mks)
- (c) Calculate the probability that a quantum state in conduction band at $E = E_C + \frac{kT}{2}$ is occupied by an electron and calculate the thermal equilibrium electron concentration in Silicon at

$T = 300\text{K}$. (Assume Fermi Energy is 0.25eV below conduction band and $N_C = 2.8 \times 10^{19} \text{ cm}^{-3}$
 $E_C - E_F = 0.25\text{eV}$) (5mks)

Question Three (14mks)

- (a) Give two reasons why silicon is the most common semiconducting material. (2mks)
- (b) Draw a diagram of a Czochralski process (CZ) crystal grower and identify all the major parts. (4mks)

- (c) Give four types of contamination found on wafer surfaces and state techniques used to keep contamination out of a cleanroom. (2mks)
- (d) Describe the difference between molecular beam epitaxy (MBE), vapor phase epitaxy (VPE), and Metalorganic chemical vapor deposition (MOCVD) systems. (6mks)

Question Four (14mks)

- (a) Sketch the Density of States function, Fermi-Dirac distribution, and areas representing electron and hole concentrations if Fermi Energy, E_F is near the midgap energy. (4mks)
- (b) Explain the differences among conductors, insulators and semiconductors using the Energy Band Diagrams. (6mks)
- (c) Silicon at $T = 300K$ contains an acceptor impurity concentration of $N_a = 10^{16} cm^{-3}$. Determine the concentration of donor impurity atoms that must be added so that the silicon is n-type and Fermi energy is 0.20eV below the conduction band edge. (4mks)

Question Five (14mks)

- (a) Explain the phenomenon of Hall Effect in semiconductors and derive the expression for Hall coefficient. Mention its applications (7mks)
- (b) A p-type silicon sample shown in Figure 5(b) below, has the following parameters:

$$L = 0.2 \text{ cm}, W = 10^{-2} \text{ cm}, d = 8 \times 10^{-4} \text{ cm}$$

$$p = 10^{16} \text{ cm}^{-3}, \mu_p = 320 \text{ cm}^2/\text{V}\cdot\text{s}$$

$$V_x = 10 \text{ V}, B_z = 500 \text{ gauss} = 5 \times 10^{-2} \text{ tesla}$$

Determine the value of I_x and V_H (7mks)

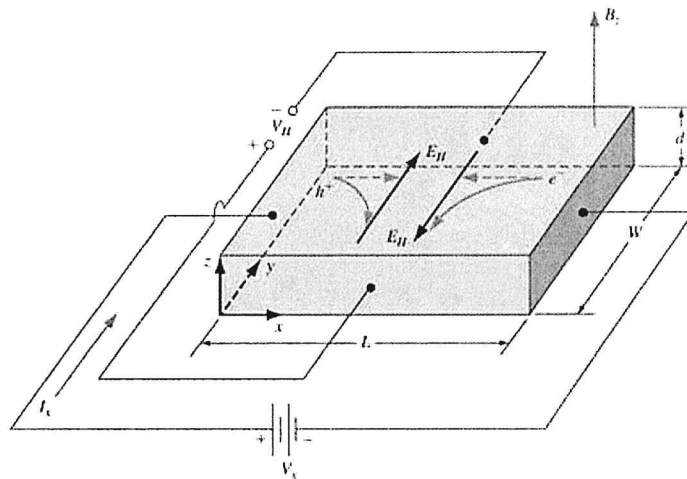


Figure 5(b)

Question Six (14mks)

- (a) Explain the effect of doping semiconductors on Fermi level. (2mks)
- (ii) Consider a p-type silicon semiconductor at $T = 300\text{ K}$ in which $N_a = 10^{16}\text{ cm}^{-3}$ and $N_d = 3.0 \times 10^{15}\text{ cm}^{-3}$. The intrinsic carrier concentration is assumed to be $n_i = 1.5 \times 10^{10}\text{ cm}^{-3}$. Determine the thermal equilibrium hole and electron concentrations. (6mks)
- (b) Differentiate with well-illustrated diagrams between degenerate and non-degenerate semiconductor (6mks)